Refine Search

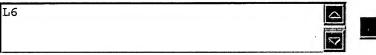
Search Results -

Terms	Documents
L1 and ((remov\$ or etch\$) near5 (oxide near4 oxynitride)).clm.	14

Database:

US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search:











Search History

DATE: Sunday, October 23, 2005 Printable Copy Create Case

Set Name Query	Hit Count	<u>Set Name</u>
side by side		result set
DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP	=ADJ	
L6 L1 and ((remov\$ or etch\$) near5 (oxide near4 oxynitride)).clm	n. 14	<u>L6</u>
<u>L5</u> L4	25	<u>L5</u>
DB = USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR = YES; OP = ADJ		
<u>L4</u> L3	25	<u>L4</u>
DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP	=ADJ	
L2 and (form\$ near4 oxide)	36	<u>L3</u>
<u>L2</u> L1 and ((remov\$ or etch\$) near5 (oxide near4 oxynitride))	74	<u>L2</u>
<u>L1</u> (ammonia or "NH.sub.3") same oxynitride same oxide	1671	<u>L1</u>

END OF SEARCH HISTORY